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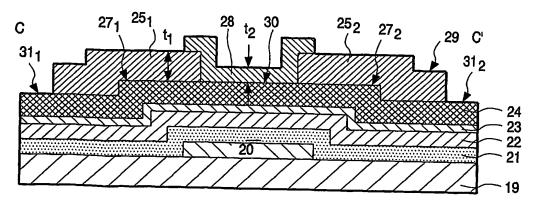
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(54) Title: METHOD OF FABRICATING A TFT DEVICE FORMED BY PRINTING



(57) Abstract: A thin-film transistor for an active matrix display is fabricated using printing means, such as a gravure offset printer. First and second pattern layers (25<sub>1</sub>, 25<sub>2</sub>; 30) are formed on a layer structure (4) wherein at least one of the layers is printed. The printed layers (25<sub>1</sub>, 25<sub>2</sub>; 30) mask regions (27<sub>1</sub>, 27<sub>2</sub>, 28) for defining source and drain terminals. The second pattern layer (28) can be removed so as to allow etching of the second region (28) for defining a channel.

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